nanni

Copper-Catalyzed Trifluoromethylthiolation of Primary and Secondary Alkylboronic Acids

Xinxin Shao, Tianfei Liu, Long Lu,* and Qilong Shen*

Key Laboratory of Organofluorine Chemistr[y,](#page-2-0) Shanghai Institute of [Org](#page-2-0)anic Chemistry, Chinese Academy of Sciences, 345 Ling-Ling Road, Shanghai 200032, China

S Supporting Information

[AB](#page-2-0)STRACT: [A Cu-cataly](#page-2-0)zed trifluoromethylthiolation of primary and secondary alkylboronic acids with an electrophilic trifluoromethylthiolating reagent is described. Tolerance for a variety of functional groups was observed.

ue to its high lipophilicity (π_R = 1.44) and strong electronegativity, the trifluoromethylthio group (CF_3S-) is generally considered a privileged structural motif that is frequently employed in new drug and agrochemical design and routinely evaluated for fine-tuning biological properties of leading compounds.¹ Consequently, development of methods for the introduction of the trifluoromethylthio group into small molecules is of grea[t](#page-2-0) interest for both academic and industrial chemists.^{2,3} In recent years, several elegant methods involving transition metal catalysis or metal-free conditions for trifluoromethylth[iola](#page-3-0)tion of aryl halides, boronic acids, and terminal alkynes employing a nucleophilic CF_3S reagent such as CF_3SAg , $CF₃SCu$, or $CF₃SNMe₄$ have been established by the research groups of Buchwald,⁴ Vicic,⁵ Qing,⁶ and Weng.⁷ Alternatively, direct trifluoromethylthiolation of indoles, 8 aryl boronic acids, 9 or alkynes 11 with [an](#page-3-0) ele[ct](#page-3-0)rophil[ic](#page-3-0) trifluoro[me](#page-3-0)thylthiolating reagent¹² were reported by Billard, S[hib](#page-3-0)ata, Rueping, an[d](#page-3-0) us.^{9a,10} M[ore](#page-3-0) recently, Gooßen reported a Sandmeyer-type trifluor[om](#page-3-0)ethylthiolation of arenediazonium salts with NaSCN an[d](#page-3-0) $TMSCF₃$ $TMSCF₃$ under mild conditions.¹³ These new methods or reagents allow the introduction of the trifluoromethylthio group at a late stage of the synthesis of the [dru](#page-3-0)g molecules.

In contrast to these significant achievements of trifluoromethylthiolation that typically involved the formation of $C(sp^2)$ –SCF₃ or $C(sp)$ –SCF₃ bonds, processes that facilitate the construction of $C(sp^3)$ −SCF₃ bonds from unactivated alkyl substrates remain much less developed. Alkyltrifluoromethylthio-ethers can be accessed through classical halogen−fluorine exchange of polyhalogenomethyl thioethers or the trifluoromethylation of sulfur-containing compounds such as disulfides, thiocyanates, and thiols via radial pathways.¹⁴ Alkyl trifluoromethylthio ethers could also be generated by the electrophilic trifluoromethylation of thiolates.¹⁵ These ind[ire](#page-3-0)ct strategies are of interest but generally require preformed sulfur precursors. Direct nucleophilic trifluoromet[hyl](#page-3-0)thiolation of alkyl halides are reported using $MSCF_{3}$ (M = Me₄N⁺, Ag(I), Cu(I), or Hg(II)) reagents (Scheme 1).¹⁶ However, these methods were mainly applied to activated alkyl halides such as benzyl, allyl, or propargyl halides or α [-h](#page-3-0)aloesters or ketones.¹⁷ Few examples for the nucleophilic trifluoromethylthiolation of simple alkyl halides

were reported previously.^{16m} More recently, Billard et al. reported the preparation of the air and moisture stable trifluoromethanesulfanyla[mides](#page-3-0) that were capable of trifluoromethylthiolation of alkenes, Grignard or lithium reagents.^{11a,18} Qing reported that the same reagent enabled trifluoromethyl-thiolation of allylsilane mediated by acid chloride.^{12b,c} [Mean](#page-3-0)while, several groups independently reported trifluoromethylthiolation of β -keto esters using different electrophi[lic tr](#page-3-0)ifluoromethylthiolating reagents in high yields.^{8b,9a,12e-g} Hu, Wang, and Rueping independently reported trifluoromethylthiolation of α diazoesters from the formation of α[-tr](#page-3-0)i[fl](#page-3-0)[uorom](#page-3-0)ethylthiolated esters.¹⁹ Despite these important advances, numerous challenges such as starting material availability, functional group tolerance, and o[per](#page-3-0)ational simplicity remain. Herein, we report the first Cucatalyzed trifluoromethylthiolation of primary (1°) and secondary (2°) alkylboronic acids with an electrophilic trifluoromethylthiolating reagent developed in our laboratory. The reaction is compatible with a variety of functional groups.

Received: July 19, 2014 Published: September 8, 2014

Alkyl boronic acids are valuable cross-coupling partners since they are crystalline compounds that can be easily prepared from alkenes or alkyl halides and are compatible with a variety of functional groups.²⁰ Direct trifluoromethylthiolation of alkyl boronic acids under mild conditions using abundant, cheap metal catalysts would pr[ov](#page-3-0)ide a new strategy for the construction of $Csp³ - SCF₃$ bond. Cu catalysts would be an ideal choice since they have been extensively employed for a variety of functional group manipulations. Unlike numerous reported reactions of aryl and alkenyl boronic acids such as the Suzuki–Miyaura reaction²¹ and Chan-Lam-Evans reaction,²² few Cu-catalyzed cross-coupling reactions of alkyl boronic acids have been reported.^{[23](#page-3-0)}

We began the study by exam[in](#page-3-0)ing the reaction between phenethylboronic acid and the electrophilic reagent 1 as a mo[de](#page-3-0)l reaction to survey the reaction conditions. When the reaction was conducted at 35 °C using 20 mol % $Cu(MeCN)_{4}PF_{6}$ and 40 mol % 2,2′-bipyridine as the catalyst in diglyme, the conditions that were efficient to promote the Cu-catalyzed trifluoromethylthiolation of arylboronic acids, no desired product was detected by GC-MS or 19 F NMR spectroscopy (Table 1, entry 1).

To our delight, when the mixture was heated to 80 °C for 36 h, the trifluoromethylthiolated product was formed in 35% yield, along with side products such as alkyl iodide and alkane from proto-deboronation (Table 1, entry 2). When the amount of alkyl boronic acid was increased to 1.5 equiv, the yield was

a Reaction conditions: alkyl boronic acid (0.15 mmol), reagent 1 (0.1 mmol), CuX (20 mol %), ligand (40 mol %), and base (2.0 equiv) in solvent (0.5 mL) at temperatures indicated in Table 1 for 12 h; yields were determined by 19F NMR analysis of the crude reaction mixture with an internal standard. $b_{1.0}$ equiv of alkylboronic acid was used.

Exection was conducted at corresponding temperature for 36 h DCE Reaction was conducted at corresponding temperature for 36 h. DCE $= 1,2$ -dichloroethane. $\binom{d}{1}$ alkyl boronic acid (1.3 equiv) was used. $\binom{d}{1}$ boronic acid (2.0 equiv) was used.

improved to 60% (Table 1, entry 3). Further screening of Cu salts showed that when $CuCl₂·2H₂O$ was used as the catalyst, the product yield improved to 73% (Table 1, entry 5). The reaction time could be significantly shortened to 12 h with a slightly increased yield when the temperature was increased to 120 °C (Table 1, entries 6−7). The amount of the alkyl boronic acid was important for the yield of the desired product. When 1.3 or 2.0 equiv of alkyl boronic acid were used, the yield decreased to 71% and 60%, respectively (Table 1, entries 8−9). The effects of the ligands and bases were further studied. Reactions were less effective when 4,4′-dimethoxy-2,2′-bipyridine L2, 4,4′-tert-butyl-2,2′-bipyridyl L3, or 1,10-phenanthroline L4 was used as the ligand (Table 1, entries 10−12). We further studied the influence of bases on the reaction. Reactions in the presence of KOAc, K_3PO_4 , Na_3PO_4 , or Na_2CO_3 gave the corresponding trifluoromethylthiolated product in lower yields than those in the presence of K_2CO_3 (Table 1, entries 13–16). Likewise, using other Cu salts such as copper(I) thiophene-2-carboxylate $(CuTc)$, $Cu(OAc)$ ₂, and $CuBr\cdot SMe$ ₂ led to slightly lower yields (Scheme 2, entries 17, 19–20). Interestingly, using CuBr_2 as the

Scheme 2. Scope of Cu-Catalyzed Trifluoromethylthiolation of 1° Alkyl Boronic Acids^{a,b}

a Reaction conditions: alkylboronic acid (0.75 mmol), reagent 1 (0.5 mmol), CuCl₂·2H₂O (20 mol %), bpy (40 mol %), and \bar{K}_2CO_3 (2.0 equiv) in 1,2-dichloroethane (2.5 mL) at 120 °C for 12 h. $\frac{b}{c}$ Isolated yield. \degree CuTc was used as the catalyst and $((2$ -phenylpropan-2yl)oxy)(trifluoromethyl)sulfane was used as the electrophilic trifluoromethylthiolating reagent in toluene.

catalyst was equally effective (Table 1, entry 18). The yield decreased significantly to 30% when the reaction was conducted in the absence of ligand (Table 1, entry 21). Likewise, no desired trifluoromethylthiolated product was observed in the absence of the Cu catalyst (Table 1, entry 22). The effects of the solvents were also evaluated. Reactions in toluene were slightly less effective, while reactions in polar solvents such as NMP, acetone, THF, or acetonitrile led to <35% yields (Table 1, entries 23−27).

With the optimized conditions (Table 1, entry 7) in hand, we then studied the substrate scope of the Cu-catalyzed trifluoromethylthiolation of 1° alkylboronic acids, as summarized in Scheme 2. A variety of alkyl boronic acids reacted with electrophilic trifluoromethylthiolating reagent 1 to give the correspo[nd](#page-1-0)ing trifluoromethylthiolated alkanes in good to excellent yields. Challenging functionalized alkyl boronic acids were compatible with the reaction conditions. Reactions of alkyl boronic acids with functional groups such as enolizable ketone, ester, alkene, nitro, amide, cyano, fluoride, chloride, and bromide occurred in good yields (Scheme 2, 3b−q). Moreover, a structurally complicated biologically active estrone derivative also reacted with trifluoromethylthiol[ate](#page-1-0)d reagent 1 to give the corresponding trifluoromethylthiolated product in good isolated yield (Scheme 2, 3q). Notably, the yield for the reaction of 6 bromohexylboronic acid and undec-10-enylboronic acid with reagent 1 on a [5](#page-1-0) or 10 mmol scale dropped significantly to give the corresponding product in 41% and 44% yield, respectively. The main side products observed for the reaction with undec-10 enylboronic acid were alkyl chloride (22%) and iodide (34%) as determined by $^1\mathrm{H}$ NMR spectroscopy and GC/MS of the crude mixture. In contrast, the same reaction in a 1.0 mmol scale gave the desired product and two side products in 71%, 15%, and 28% yield, respectively (Scheme 2, 3d).

Encouraged by these excellent results, we next turned our attention to 2° alkylboron[ic](#page-1-0) acids that are more challenging substrates in organic synthesis. The reaction conditions were slightly modified, and we found the highest yields were obtained when CuTc was used as the catalyst. Other Cu salts such as CuBr₂, CuSCN, CuI, CuBr, Cu(OAc)₂, CuCN, CuBr·SMe₂, or $CuCl₂·2H₂O$ were slightly less effective. However, much less side products were observed when CuTc was used as the catalyst (Table 2). Under these conditions, several cyclic and acyclic 2°

Table 2. Optimization of Reaction Conditions for Trifluoromethylthiolation of 2° Alkyl Boronic Acids^{a,b}

a Reaction conditions: alkylboronic acid (0.15 mmol), reagent 1 (0.1 mmol), Cu catalyst (20 mol %), bpy (40 mol %), and K_2CO_3 (2.0 equiv) in 1,2-dichloroethane (2.5 mL) at 120 °C for 12 h. b Yields were determined by ¹⁹F NMR with an internal standard.

alkyl boronic acids could be successfully trifluoromethylthiolated in good yields, as shown in Scheme 3. More importantly, ketones, esters, and N-protected piperidines were well tolerated with the reaction conditions (Scheme 3, 4f−h). In addition, the reaction was not significantly affected by the ring size of the cyclic 2° alkyl boronic acids. Five-, six-, seven-, and twelve-membered cyclic alkyl boronic acids all reacted with reagent 1 to give the corresponding trifluoromethylthiolated products in good isolated yields (Scheme 3, 4a−b, 4d−e).

In conclusion, we report the first Cu-catalyzed trifluoromethylthiolation of 1° and 2° alkylboronic acids with an electrophilic trifluoromethylating reagent.²³ The advantage of Scheme 3. Scope of Cu-catalyzed Trifluoromethyl-thiolation of 2° Alkyl Boronic Acids^{*a*,b}

a Reaction conditions: alkylboronic acid (0.75 mmol), reagent 1 (0.5 mmol), CuTc (20 mol %), bpy (40 mol %), and K_2CO_3 (2.0 equiv) in 1,2-dichloroethane (2.5 mL) at 120 °C for 12 h. b Isolated yield.

the current method compared to the previous method using a Grignard or lithium reagent is its tolerance for a variety of functional groups. Thus, potentially, it will provide a general method for the construction of any desired trifluoromethylthiosubstituted alkyl building blocks. Further investigation of the more challenging stereospecific trifluoromethylthiolation of 2° alkyl boronic acids and mechanistic studies of the reaction are underway in our laboratory.

■ ASSOCIATED CONTENT

S Supporting Information

Experimental procedures, characterization data. This material is available free of charge via the Internet at http://pubs.acs.org.

■ AUTHOR INFORMATION

Corresponding Authors

*E-mail: shenql@sioc.ac.cn.

*E-mail: lulong@sioc.ac.cn.

Notes

The authors declare no competing financial interest.

■ ACKNOWLEDGMENTS

The authors gratefully acknowledge the financial support from the National Basic Research Program of China (2012CB821600), National Natural Science Foundation of China (21172244/21172245/21372247), Agro-scientific Research in the Public Interest (201103007), the National Key Technologies R&D Program (2011BAE06B05), Shanghai Scientific Research Program (10XD1405200), and SIOC for financial support.

■ REFERENCES

(1) (a) Hansch, C.; Leo, A.; Elkins, D. Chem. Rev. 1971, 71, 525. (b) Filler, R. Biomedical Aspests of Fluorine Chemsitry; Kodansha: Tokyo, 1982. (c) Yagupolskii, L. M.; Ilchenko, A. Y.; Kondratenko, N. V. Russ. Chem. Rev. 1974, 43, 32. (d) Hansch, C.; Leo, A.; Taft, R. W. Chem. Rev. 1991, 91, 165. (e) Becker, A. Inventory of Industrial Fluoro-Biochemicals; Eyrolles: Paris, 1996. (f) Leroux, F.; Jeschke, P.; Schlosser, M. Chem. Rev. 2005, 105, 827. (g) Mantear, B.; Pazenok, S.; Vors, J.-P.; Leroux, F. R. J. Fluorine Chem. 2010, 131, 140.

(2) (a) Boiko, V. N. Beilstein J. Org. Chem. 2010, 6, 880. (b) Tlili, A.; Billard, T. Angew. Chem., Int. Ed. 2013, 52, 6818. (c) Liang, T.; Neumann, C. N.; Ritter, T. Angew. Chem., Int. Ed. 2013, 52, 8214. (d) Toulgoat, F.; Alazet, S.; Billard, T. Eur. J. Org. Chem. 2014, 2415.

(3) Selected examples for classic methods of trifluoromethylthiolation: (a) Nodiff, E. A.; Lipschutz, S.; Craig, P. N.; Gordon, M. J. Org. Chem. 1960, 25, 60. (b) Feiring, A. E. J. Org. Chem. 1979, 44, 2907. (c) Boiko, V. N.; Shchupak, G. M.; Yagupolskii, L. M. Zh. Org. Khim. 1977, 13, 1057. (d) Wakeselman, C.; Tordeux, M. J. Org. Chem. 1985, 50, 4047. (e) Koshechko, V. G.; Kiprianova, L. A.; Fileleeva, L. I. Tetrahedron Lett. 1992, 33, 6677. (f) Billard, T.; Langlois, B. R. Tetrahedron Lett. 1996, 67, 6865. (g) Quiclet-Sire, B.; Saicic, R. N.; Zard, S. Z. Tetrahedron Lett. 1996, 37, 9057. (h) Russell, J.; Roques, N. Tetrahedron 1998, 54, 13771. (i) Billard, T.; Roques, N.; Langlois, B. R. J. Org. Chem. 1999, 64, 3813. (j) Harsányi, A.; Dorkó, E.; Csapó, A.; Bakó, T.; Peltzb, C.; Rábai, J. J. Fluorine Chem. 2011, 132, 1241.

(4) Teverovskiy, G.; Surry, D. S.; Buchwald, S. L. Angew. Chem., Int. Ed. 2011, 50, 7312.

(5) (a) Zhang, C. P.; Vicic, D. A. J. Am. Chem. Soc. 2012, 134, 183. (b) Zhang, C. P.; Vicic, D. A. Chem.- Asian J. 2012, 7, 1756.

(6) (a) Chen, C.; Chu, L.; Qing, F. L. J. Am. Chem. Soc. 2012, 134, 12454. (b) Chen, C.; Xie, Y.; Chu, L.; Wang, R. W.; Zhang, X. G.; Qing, F. L. Angew. Chem., Int. Ed. 2012, 51, 2492.

(7) (a) Weng, Z.; He, W.; Chen, C.; Lee, R.; Dan, D.; Lai, Z.; Kong, D.; Yuan, Y.; Huang, K.-W. Angew. Chem., Int. Ed. 2013, 52, 1548. (b) Tan, J.-W.; Zhang, G.-T.; Ou, Y.-L.; Yuan, Y.-F.; Weng, Z. Chin. J. Chem. 2013, 31, 921. (c) Zhu, P.; He, X.; Chen, X.-Q.; You, Y.; Yuan, Y.-F.; Weng, Z. Tetrahedron 2014, 70, 672.

(8) (a) Ferry, A.; Billard, T.; Bacque, E.; Langlois, B. R. J. Fluorine Chem. 2012, 134, 160. (b) Yang, Y. D.; Azuma, A.; Tokunaga, E.; Yamasaki, M.; Shiro, M.; Shibata, N. J. Am. Chem. Soc. 2013, 135, 8782. (9) (a) Shao, X.; Wang, X.; Yang, T.; Lu, L.; Shen, Q. Angew. Chem., Int. Ed. 2013, 52, 3457. (b) Vinogradova, E.; Müller, P.; Buchwald, S. L. Org. Lett. 2014, 53, 3125. (b) Pluta, R.; Nikolaienko, P.; Rueping, M. Angew. Chem., Int. Ed. 2014, 53, 150. (c) Kang, K.; Xu, C.-F.; Shen, Q. Org. Chem. Front. 2014, 1, 294. (d) Feng, H.; Shao, X.-X.; Zhu, D.-H.; Lu, L.; Shen, Q. Angew. Chem., Int. Ed. 2014, 53, 61050.

(10) The structure of reagent 1 was originally proposed to be trifluoromethylthio-substituted hypervalent iodine, which was revised by Buchwald et al. to be trifluoromethyl-substituted thioperoxide based on a combination of spectroscopic techniques, derivatization experiments, and the crystalline sponge method. Vinogradova, E.; Müller, P.; Buchwald, S. L. Angew. Chem., Int. Ed. 2014, 53, 3125.

(11) (a) Baert, F.; Colomb, J.; Billard, T. Angew. Chem., Int. Ed. 2012, 51, 10382. (b) Alazet, S.; Zimmer, L.; Billard, T. Angew. Chem., Int. Ed. 2013, 52, 10814.

(12) Other reactions with electrophilic trifluoromethylthiolated reagents: (a) Ferry, A.; Billard, T.; Langlois, B. R.; Bacque, E. J. Org. Chem. 2008, 73, 9362. (b) Yang, Y.; Jang, X. L.; Qing, F. L. J. Org. Chem. 2012, 77, 7538. (c) Liu, J.; Chu, L.; Qing, F. L. Org. Lett. 2013, 15, 894. (d) Yagupolskii, L. M.; Kondratenko, N. V.; Timofeeva, G. N. J. Org. Chem. USSR 1984, 20, 103. (e) Bootwicha, T.; Liu, X.; Pluta, R.; Atodiresei, I.; Rueping, M. Angew. Chem., Int. Ed. 2013, 52, 12856. (f) Wang, X.-Q.; Yan, T.; Cheng, X.-L.; Shen, Q. Angew. Chem., Int. Ed. 2013, 52, 12860. (g) Deng, Q.-H.; Rettenmeier, C.; Wadepohl, H.; Gade, L. H. Chem.-Eur. J. 2014, 20, 93. (h) Wang, K.-P.; Yun, S.-Y.; Mamidipalli, P.; Lee, D. Chem. Sci. 2013, 4, 3205. (i) Zhai, L.; Li, Y.; Yin, J.; Jin, K.; Zhang, R.; Fu, X.; Duan, C.-Y. Tetrahedron 2013, 69, 10262. (j) Tran, L. D.; Popov, I.; Daugulis, O. J. Am. Chem. Soc. 2012, 134, 18237. (k) Nikolaienko, P.; Pluta, R.; Rueping, M. Chem.-Eur. J. 2014, 20, 9867. (l) Rueping, M.; Liu, X.; Bootwicha, T.; Pluta, R.; Merkens, C. Chem. Commun. 2014, 50, 2508.

(13) Danoun, G.; Bayarmagnai, B.; Grü nberg, M. F.; Gooßen, L. J. Chem. Sci. 2014, 5, 1312.

(14) Selected examples of radical trifluoromethylation of alkyl thiols or disulfides: (a) Billard, T.; Langlois, B. R. Tetrahedron Lett. 1996, 37, 6865. (b) Billard, T.; Large, S.; Langlois, B. R. Tetrahedron Lett. 1997, 38, 65. (c) Billard, T.; Roques, N.; Langlois, B. R. J. Org. Chem. 1999, 64, 3813. (d) Large, S.; Rpques, N.; Langlois, B. R. J. Org. Chem. 2000, 65,

8848. (e) Blond, G.; Billard, T.; Langlois, B. R. Tetrahedron Lett. 2001, 42, 2473. (f) Pooput, C.; Médebielle, M.; Dolbier, J. W. R. Org. Lett. 2004, 6, 301. (g) Pooput, C.; Dolbier, J. W. R.; Médebielle, M. J. Org. Chem. 2006, 71, 3564. (h) Magnier, E.; Wakeselman, C. Synthesis 2003, 565. (i) Langlois, B. R.; Billard, T.; Mulatier, J.-C.; Yezeguelian, C. J. Fluorine Chem. 2007, 128, 851. (j) Yasui, H.; Yamamoto, T.; Tokunaga, E.; Shibata, N. J. Fluorine Chem. 2011, 132, 186.

(15) (a) Umemoto, T.; Ishihara, S. Tetrahedron Lett. 1990, 31, 3579. (b) Umemoto, T.; Ishihara, S. J. Am. Chem. Soc. 1993, 115, 2156. (c) Kieltsch, I.; Eisenberger, P.; Togni, A. Angew. Chem., Int. Ed. 2007, 46, 754.

(16) Selected examples of nucleophilic trifluoromethylation of activated alkyl halides: (a) Man, E. H.; Coffman, D. D.; Muetterties, E. L. J. Am. Chem. Soc. 1959, 81, 3575. (b) Orda, V. V.; Yagupol'skii, L. M.; Bystrov, V. F.; Stepanyamts, A. U. Zh. Obshch. Khim. 1965, 35, 1628. (c) Harris, J. F. J. Org. Chem. 1966, 31, 931. (d) Harris, J. F. J. Org. Chem. 1967, 32, 2063. (e) Sheppard, W. A. Tetrahedron 1971, 27, 945. (f) Yagupol'skii, L. M.; Smimova, O. D. Zhur. Org. Khim. 1972, 8, 1990. (g) Hanack, M.; Massa, F. W. Tetrahedron Lett. 1971, 22, 557. (h) Borowski, H. E.; Hass, A. Chem. Ber. 1982, 115, 533. (i) Haas, A.; Krächter, H.-U. Chem. Ber. 1988, 121, 1833. (j) Hass, A.; Lieb, M.; Steffens, B. J. Fluorine Chem. 1992, 56, 55. (k) Munavalli, S.; Rossman, D. I.; Rohrbaugh, D. K.; Ferguson, C. P.; Durst, H. D. J. Fluorine Chem. 1996, 76, 7. (l) Kolomeitsev, A.; Medebielle, M.; Kirsh, P.; Lork, E.; ́ Röschenthaler, G.-V. J. Chem. Soc., Perkin Trans. 1 2000, 2183. (m) Tyrra, W.; Naumann, D.; Hoge, B.; Yagupolskii, Y. L. J. Fluorine Chem. 2003, 119, 101. (n) Kong, D.; Jiang, Z.; Xin, S.; Bai, Z.; Yuan, Y.; Weng, Z. Tetrahedron 2013, 69, 6046. (o) Li, S.-G.; Zard, S. Z. Org. Lett. 2013, 15, 5898. (p) Lin, Q.; Chen, L.; Huang, Y.; Rong, M.; Yuan, Y.; Weng, Z. Org. Biomol. Chem. 2014, 12, 5500. (q) Huang, Y.; He, X.; Lin, X.; Rong, M.; Weng, Z. Org. Lett. 2014, 16, 3284. (r) Wang, Z.; Tu, Q.; Weng, Z. J. Organomet. Chem. 2014, 751, 830.

(17) Less than 15% yields were observed for reactions of 3 phenoxypropyl bromide with $AgSCF₃$ in DMF, DMSO, $CH₃CN$, acetone, or dioxane at rt or 100 °C for 8 h. Likewise, <3% yields were observed for reactions of bromocycloheptane with $AgSCF₃$ in DMF, DMSO, CH₃CN, acetone, or dioxane at 100 $^{\circ}$ C for 8 h.

(18) Ferry, A.; Billard, T.; Langlois, B. R.; Bacque, E. Angew. Chem., Int. Ed. 2009, 48, 8551.

(19) During the review process of the manuscript, Hu, Wang, and Rueping independently reported two Cu-mediated trifluoromethylthiolations of diazo compounds: (a) Wang, X.; Zhou, Y.-J.; Ji, G.-J.; Wu, G.-J.; Li, M.; Zhang, Y.; Wang, J.-B. Eur. J. Org. Chem. 2014, 3093. (b) Hu, M.-Y.; Rong, J.; Miao, W.-J.; Ni, C.-F.; Han, Y.-X.; Hu, J.-B. Org. Lett. 2014, 16, 2030. (c) Lefebvre, Q.; Fava, E.; Nikolaienko, P.; Rueping, M. Chem. Commun. 2014, 50, 6617.

 (20) (a) Doucet, H. E. J. Org. Chem. 2008, 2013. (b) Molander, G. A.; Ellis, N. Acc. Chem. Res. 2007, 40, 275−286.

(21) Miyaura, N.; Suzuki, A. Chem. Rev. 1995, 95, 2457.

(22) (a) Qiao, J.; Lam, P. Y. S. Synthesis 2011, 6, 829. (b) Lam, P. Y. S.; Clark, C. G.; Saubern, S.; Adams, J.; Winters, M. P.; Chan, D. M. T.; Combs, A. Tetrahedron Lett. 1998, 39, 2941. (c) Herradura, P. S.; Pendola, K. A.; Guy, R. K. Org. Lett. 2000, 2, 2019. (d) Savarin, C.; Srogl, J.; Liebeskind, L. S. Org. Lett. 2002, 4, 4309. (e) Kao, H.; Chen, C.; Wang, Y.; Lee, C. Eur. J. Org. Chem. 2011, 1776. (f) Lin, Y.; Wang, Y.; Lin, C.; Cheng, J.; Lee, C. J. Org. Chem. 2012, 77, 6100. (g) Cheng, J.; Yi, C.; Liu, T.; Lee, C. Chem. Commun. 2012, 48, 8440.

(23) Selected examples of Cu-mediated cross-coupling of alkyl boronic acids: (a) Ohishi, T.; Zhang, L.; Nishiura, M.; Hou, Z. Angew. Chem., Int. Ed. 2011, 50, 8114. (b) Ohmiya, H.; Yokobori, U.; Makida, Y.; Sawamura, M. J. Am. Chem. Soc. 2010, 132, 2895. (c) Ohmiya, H.; Yoshida, M.; Sawamura, M. Org. Lett. 2011, 13, 482. (d) J. Xu, J.; Xiao, B.; Xie, C.; Luo, D.; Liu, L.; Fu, Y. Angew. Chem., Int. Ed. 2012, 51, 12551. (e) Ohmiya, H.; Tanabe, M.; Sawamura, M. Org. Lett. 2011, 13, 1086.